

Fig.1. Dependence of GPC for ALD temperature.

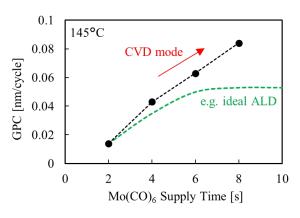


Fig.2. Dependence of GPC for Mo(CO)<sub>6</sub> supply time.

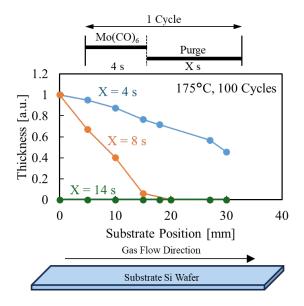


Fig.3. Film thickness at substrate position

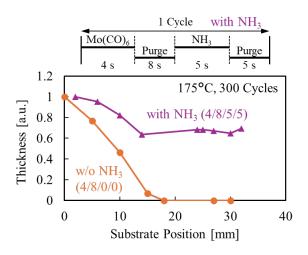


Fig.4. Film thickness at substrate position with and without NH<sub>3</sub>.

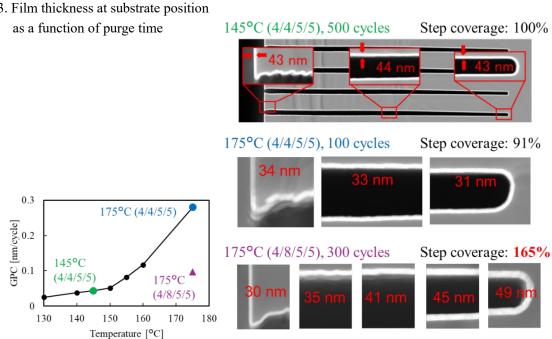


Fig.5. Step coverage in trench pattern with A/R=40.